

# Detached Melt and Vapor Growth of InI in SUBSA Hardware

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# OVERVIEW

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- **Introduction**
- **SUBSA furnace**
- **Wetting angle results for InI on different substrates**
- **Ampoule setups**
- **Conclusions**

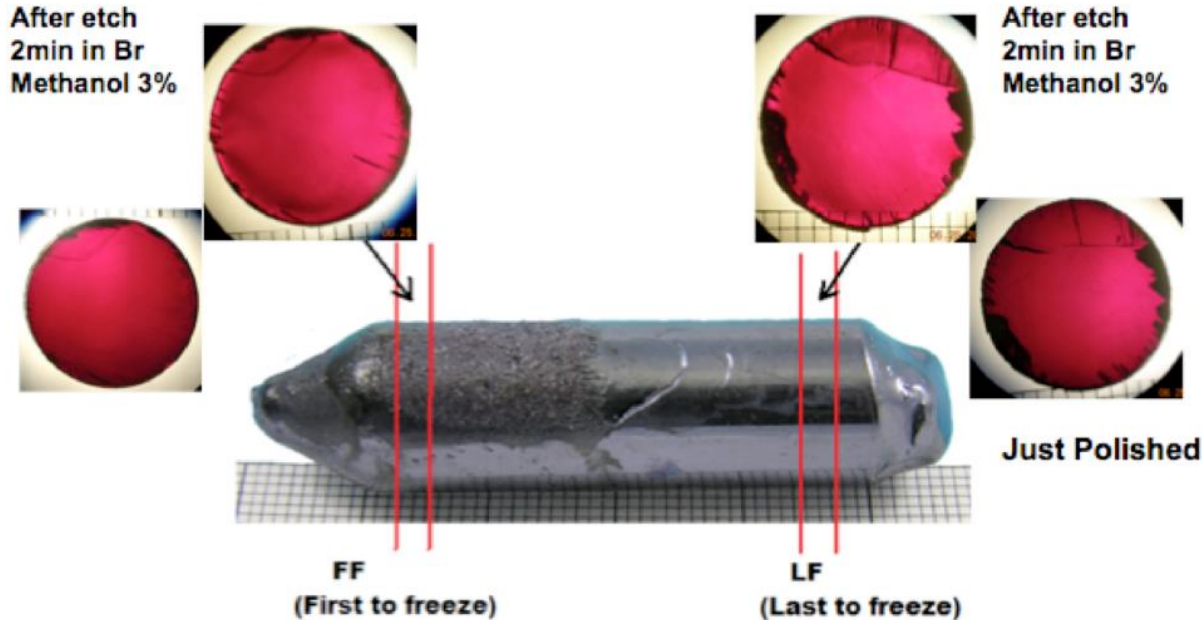
# INTRODUCTION (I)

- **Monovalent Indium Iodide, InI, is a promising candidate for  $\gamma$ -ray and X-ray detectors**

Material	$\text{Cd}_{0.9}\text{Zn}_{0.1}\text{Te}$ (CZT)	$\text{HgI}_2$	InI
Average atomic number, Z	49.1	62	51
Density, $\text{g/cm}^3$	5.78	6.4	5.31
Band gap, eV	1.55	2.14	2.0
Melting point, $^\circ\text{C}$	$\sim 1100$	259	351
Structure	Zincblende	Tetrahedral-layered	Orthorhombic
Knoop Hardness, $\text{kg/mm}^2$	92	10	27
Molecule Disassoc. Energy eV Herzberg's tables [19]	1.2	0.35	3.43
Electrical Resistivity, Ohm-cm	$3 \times 10^{10}$	$10^{13}$ to $10^{14}$	$5 \times 10^{11}$

# INTRODUCTION (II)

- The low melting point and congruent sublimation allow both melt growth and vapor growth.
- InI is not toxic and not hygroscopic



*VB-grown crystal and wafers (IIT)*



*CZ-grown crystals (IIT)*

# INTRODUCTION (III)

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- Current problems with InI are:
  - Purity of the starting material. IIT has developed considerable experience in purifying In and I, synthesizing InI from the elements, and further purifying InI by zone melting.
  - The formation of small inclusions in the grown material. These are thought to be responsible for the reduced electronic properties, compared to theoretical values
- Growth under  $\mu g$ 
  - allows vapor growth under purely diffusive conditions, which has shown to lead to a significantly increased  $\mu\text{-}\tau$  product in the case of  $\text{HgI}_2$  [1]
  - enhances the chance for detachment in the case of Bridgman growth to reduce stress in the crystal

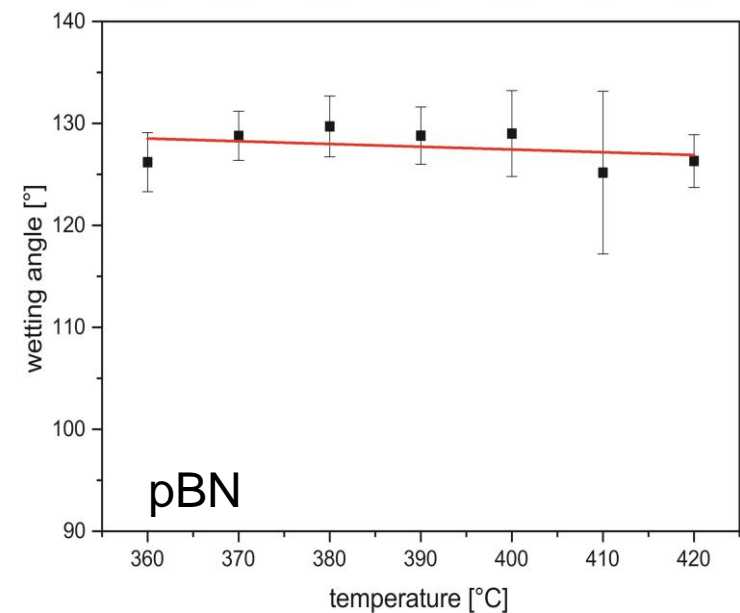
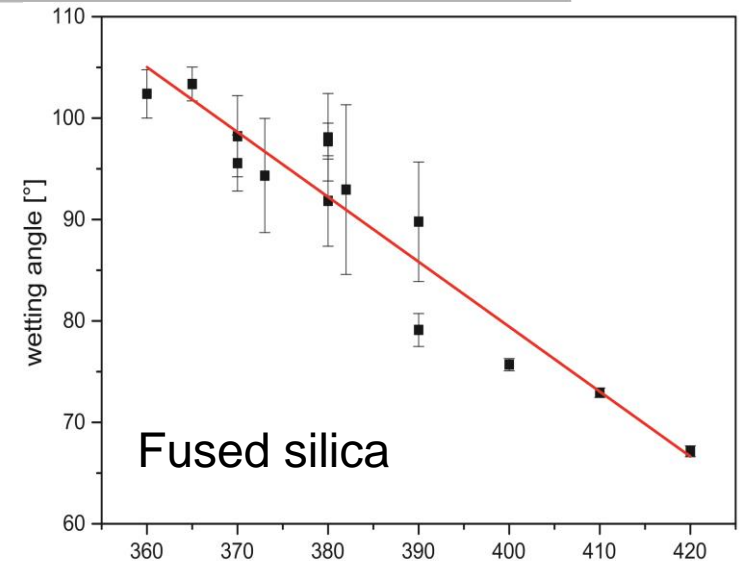
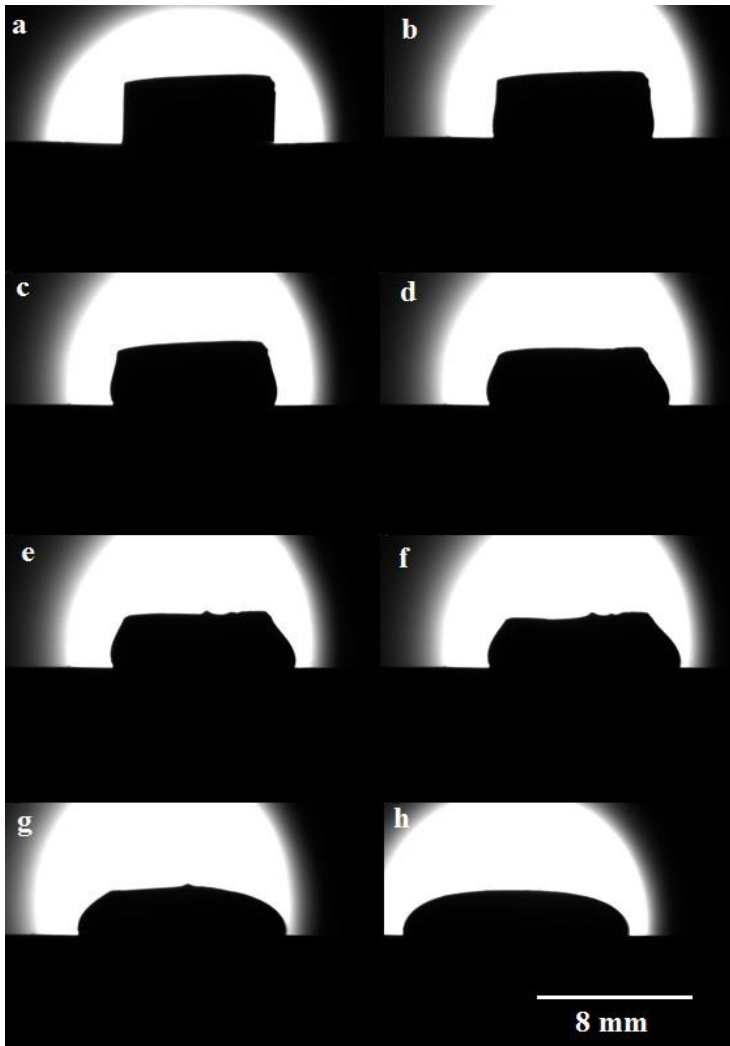
[1] L. Van den Berg and W.F. Schneppe: Mercuric iodide crystal growth in space. Nucl. Instrum. A 283 (1989), 335-338

# SUBSA FURNACE

- Was developed for a series of InSb experiments with a *submerged* baffle in the ISS MSG (microgravity science glovebox) rack.
- One heating zone, low power consumption
- Transparent gradient zone to visualize the growth interface



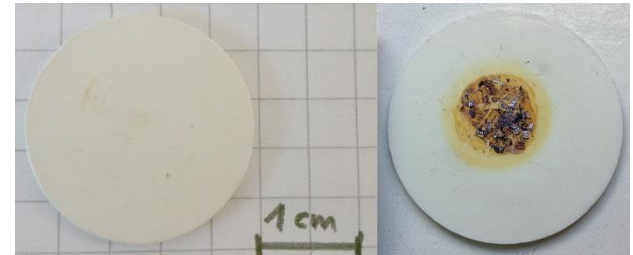
# WETTING: SESSILE DROP TESTS





# WETTING: SESSILE DROP RESULTS

- Wetting angle of InI on fused silica:  $105 \pm 2.6^\circ$   
temperature coefficient:  $-0.64 \pm 0.06$  degree/K(!), sample slides off the substrate easily
- Wetting angle of InI on pBN:  $128 \pm 2.3$   
temperature coefficient:  $-0.03 \pm 0.03$  degree/K, **but** sample sticks and reacts with the substrate  
( $3\text{InI} + 2\text{BN} \rightleftharpoons \text{In}_3\text{BN}_2 + \text{BI}_3$ )



- Wetting angle of InI on  $\text{Al}_2\text{O}_3$  ceramics:  $101.6 \pm 2.1^\circ$   
temperature coefficient:  $-0.315 \pm 0.007$  degree/K [1]
- Wetting angle of InI on carbon:  $93.4 \pm 0.7^\circ$   
temperature coefficient:  $-0.102 \pm 0.006$  degree/K [1]

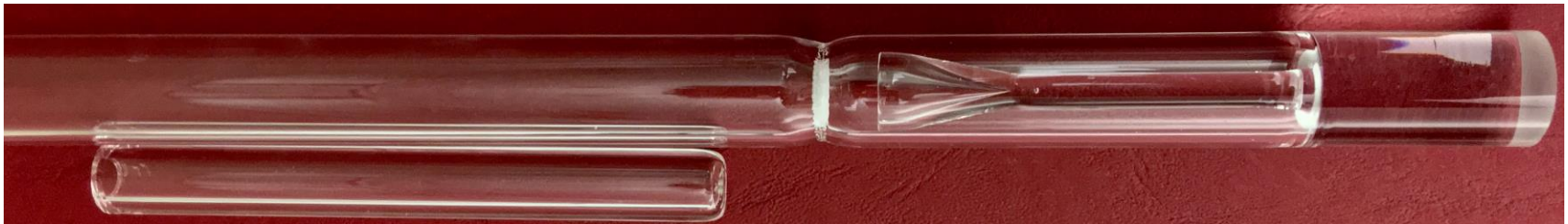
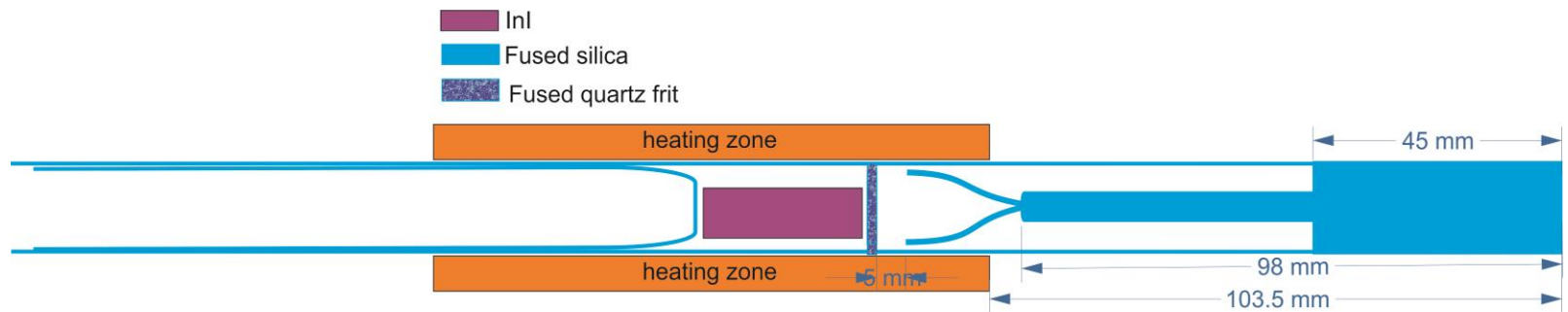
[1] S.C. Fischer, Ph.D. thesis, Technical University of Aachen and FZ Jülich, 2009. In: Schriften des Forschungszentrums Jülich, Energy & Environment Vol. 44 (2009), pp. 44, 46, 73-75, 135.

<http://hdl.handle.net/2128/3722>



# VAPOR PHASE AMPOULE

## Modified Markov method setup



# CONCLUSIONS

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- **InI has promising properties as room temperature  $\gamma$ -ray detector**
- **The low melting point allows Bridgman growth and CZ growth, although diameter control is difficult with the latter method**
- **Determination of the wetting angles with different crucible materials showed the highest value (128°) for pBN, but InI and pBN react, whereas fused silica (105°) does not react. Other materials better suitable for detachment have to be tested, e.g. DLC coatings.**
- **The congruent sublimation also allows vapor phase growth in comparison to melt growth**
- **The  $\mu$ g experiments in the “SUBSA“ furnace on the ISS are planned for 2017**

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**THANK YOU FOR YOUR ATTENTION!**



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